

IN THE CLAIMS:

1. (Currently Amended) An element mapping unit that generates a distribution image of an element contained in an object to be analyzed on the basis of the energy spectrum of the electron beam transmitted through the object to be analyzed and the irradiation position of the electron beam on the object to be analyzed; comprising:

an accelerating tube within an electron spectrometer, connected to a scanning transmission electron microscope, which accelerates the electron beam transmitted through the object to be analyzed;

an electron spectrometer that analyzes into a spectrum the energy of the electron beam transmitted through the object to be analyzed;

an electron beam detector that detects the intensity of the electron beam;

a control unit that controls the accelerating tube so that the electron beam, which has lost specific energy corresponding to the element to be analyzed, enters into a fixed position in the electron beam detector and detects in real time the element to be analyzed on the basis of the intensity of the electron beam within a predetermined energy range out of those electron beam intensities detected above,

wherein the electron beam detector contains multiple electron beam detecting sections corresponding to the electron beam energy,

said control unit includes a storage section, a control section, and a computation section,

said storage section stores the acceleration voltage for accelerating the electron beam that has loss specific energy, and a 1st energy range, which is a range including core loss peak, and a 2nd energy range, which is a range lower than the core loss energy, out of an electron energy loss spectrum of the element to be analyzed,

said control section detects a 1st electron beam intensity detected by the electron beam detecting section corresponding to the 1st energy range and a 2nd electron beam intensity detected by the electron beam detecting section corresponding to the 2nd energy range on the basis of the stored 1st energy range and 2nd energy range, and

said computation section divides the 1st electron beam intensity by the 2nd electron beam intensity so as to detect the element to be analyzed.

2. (Canceled).

3. (Previously Presented) An element mapping unit according to Claim 1,
wherein

the storage section stores correction data for eliminating the effect peculiar to the electron beam detector from the detected electron beam; and

the computation section corrects the detected electron beam in accordance with the correction data.

4. (Canceled).

5. (Previously Presented) An element mapping unit according to Claim 1,
wherein

the storage section further stores a 3rd energy range, which is in a range smaller than the core loss energy, out of an inner shell electron energy loss spectrum of the element to be analyzed;

the control section further detects a 3rd electron beam intensity detected by the electron beam detecting section corresponding to the 3rd energy range on the basis of the stored 3rd energy range;

the computation section acquires the background intensity of the 1st energy range in accordance with the 2nd electron beam intensity and 3rd electron beam intensity, and calculates the difference between the 1st energy range and the acquired background intensity so as to detect the element to be analyzed.

6. (Previously Presented) An element mapping unit according to Claim 1,
wherein

the storage section stores a plasmon energy range including a plasmon peak out of the inner shell electron energy loss spectrum of the element to be analyzed;

the control unit detects the plasmon loss intensity of the electron beam detected by the electron beam detector corresponding to the plasmon energy range on the basis of the stored plasmon loss energy range; and

the computation section detects the element to be analyzed on the basis of the detected plasmon loss intensity.

7. (Original) An element mapping unit according to Claim 1, wherein the control unit controls the accelerating tube so that the 1st electron beam, which has lost specific energy corresponding to the 1st element to be analyzed, enters into a fixed position in the electron beam detector; detects the 1st element on the basis of the 1st electron beam intensity in a predetermined energy range out of the detected 1st electron beam intensities; when the 2nd element to be analyzed is inputted from the outside, controls the accelerating tube so that the 2nd electron beam, which has lost specific energy corresponding to the 2nd element to be analyzed, enters into a fixed position in the electron beam detector; and detects the 2nd element on the basis of the 2nd electron beam intensity in a predetermined energy range out of the detected 2nd electron beam intensities;

8. (Previously Presented) A scanning transmission electron microscope, equipped with the element mapping unit according to Claim 1, that irradiates electron beams onto an object to be analyzed and supplies the electron beams, which have transmitted through the object to be analyzed, to the element mapping unit.

9. (Previously Presented) An element mapping method that generates a distribution image of an element contained in an object to be analyzed on the basis of the energy spectrum of the electron beam transmitted through the object to be analyzed and the irradiation position of the electron beam on the object to be analyzed; including a step for irradiating electron beams onto the object to be analyzed by using a scanning transmission electron microscope; a step for accelerating the electron beam transmitted through the object to be analyzed; a step for analyzing into spectrum the energy of the electron beam transmitted through the object to be analyzed; a step for detecting the intensity of the electron beam by an electron beam detector;

a step for detecting an element to be analyzed on the basis of the electron beam intensity; and

a step for moving the position of the electron beams to be irradiated onto the object to be analyzed; wherein

the step for acceleration includes a step for accelerating the electron beam so that the electron beam, which has lost specific energy corresponding to the element to be analyzed, enters into a fixed position in the electron beam detector;

the step for detecting the element includes a step for detecting the element to be analyzed on the basis of the intensity of the electron beam within a predetermined energy range out of those electron beam intensities detected above, further including

a step for changing the element to be analyzed to another element;

a step for accelerating the electron beam so that the electron beam, which has lost specific energy corresponding to the other element, enters into a fixed position in the electron beam detector; and

a step for detecting the other element to be analyzed on the basis of the intensity of the electron beam within a predetermined energy range corresponding to the other element out of those electron beam intensities that are detected when the electron beam, which has lost specific energy corresponding to the other element, enter into the electron beam detector.

10. (Canceled).